

# Irradiation Plan for 2009

- VCSEL/PIN irradiation in pre-qualification:
  - ~2 devices/vendor
  - process will continue for any newly available device
  - PIN received  $\frac{1}{2}$  SLHC dose in Aug. 2008
    - ⇒ re-qualify Optowell (GaAs) and Hamamatsu (Si)?
- VCSEL/PIN irradiation with large sample
  - ~20 devices/vendor
  - VCSEL: AOC 10 Gb/s, ~~AOC 5 Gb/s, Optowell (2.5 Gb/s)~~
  - GaAs PIN: try to order 12-channel Hamamatsu bare dice
- Irradiation facility: 24 GeV protons at CERN in Aug. 2009
  - irradiate 2 devices from selected vendors at end of 2009 or early 2010 with  $\pi$ 's @ PSI for NIEL hypothesis testing?

# Irradiation Test System

- Temperature will be measured but not controlled
- VCSEL:
  - will monitor LIV curve for 2 devices/vendor
    - remaining 18 devices will be powered
    - will monitor LIV if feasible
  - will irradiate for ~8 hours/day and then anneal
- PIN:
  - mode scrambler will be installed for two arrays
    - will monitor PIN currents of these two arrays
    - remaining 18 devices will be powered
      - ◆ will illuminate the devices if feasible
  - cannot move the devices during irradiation

# Control Sample of PIN

- Hamamatsu S5973?
  - ❑ single-channel Si 850 nm device
  - ❑ bandwidth: 1 Gb/s
  - ❑ loss ~40% of responsivity at  $1.5 \times 10^{15}$  1-MeV  $n_{eq}/\text{cm}^2$
  - ❑ metallic package highly radioactive after irradiation
- Hamamatsu G8921?
  - ❑ 4-12 channel GaAs 850 nm array
  - ❑ bandwidth: 2.5 Gb/s
  - ❑ loss ~60% of responsivity at  $8.2 \times 10^{15}$  1-MeV  $n_{eq}/\text{cm}^2$
  - ❑ pre-mounted on ceramic
    - ⇒ need custom alignment

# Control Sample of VCSEL

- AOC 10 Gb/s?
  - ❑ 12 channel GaAs 850 nm array
  - ❑ bandwidth: 10 Gb/s
  - ❑ expensive: ~\$300, including packaging